ATTY UKT. NO.. AMA I /8338/DSM/LOW K/JW U.S. SERIAL NO.: UNKNOWN

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METHODS OF REDUCING PLASMA-INDUCED DAMAGE FOR

ADVANCED PLASMA CVD DIELECTRICS INVENTOR:

LIHUA LI, ET AL.

Γ

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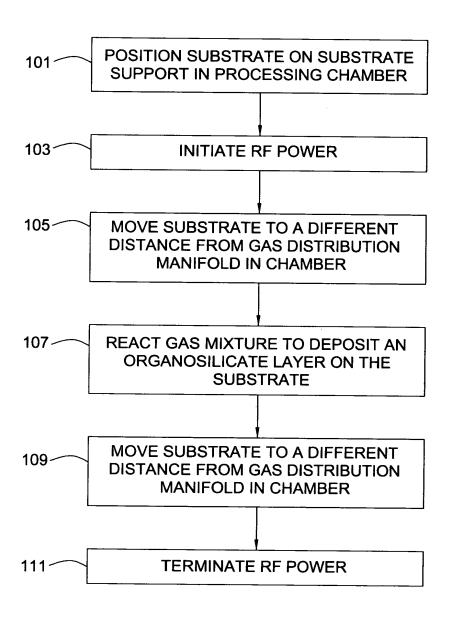


FIG. 1

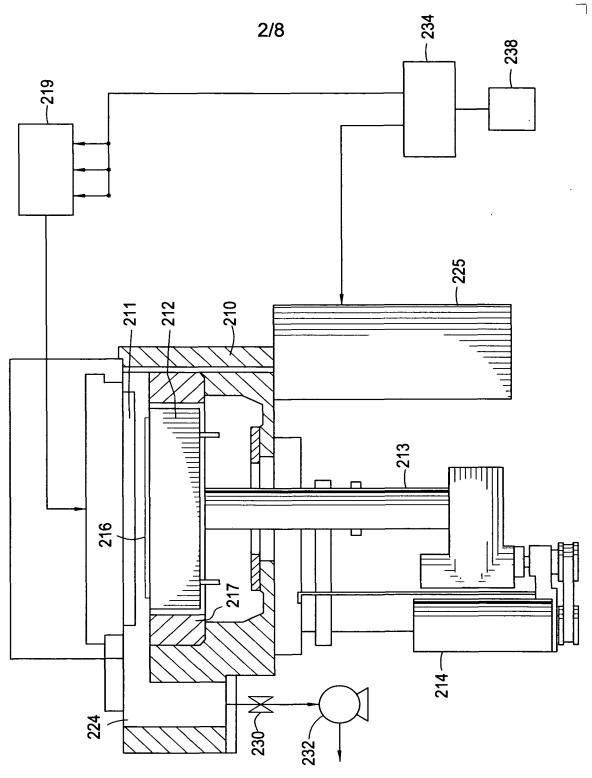
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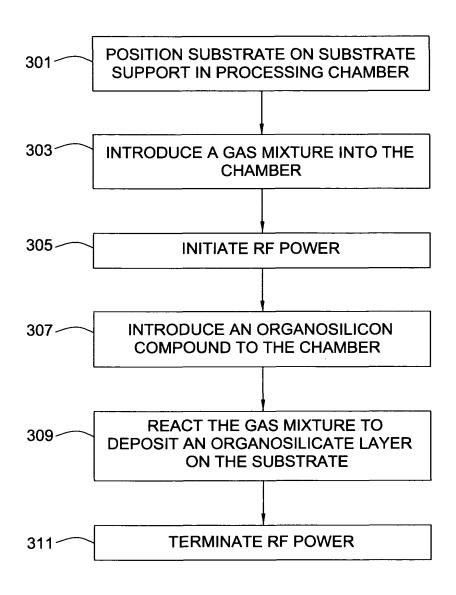


FIG. 3

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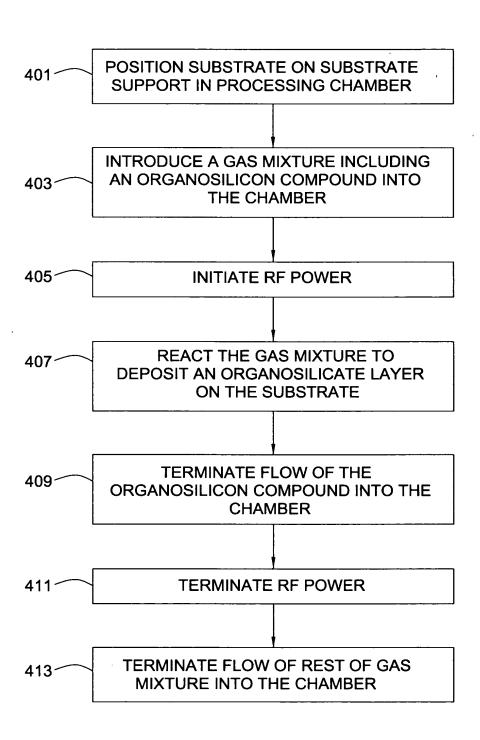


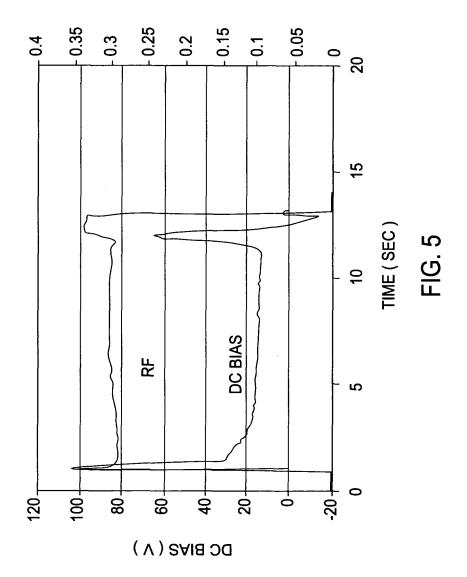
FIG. 4

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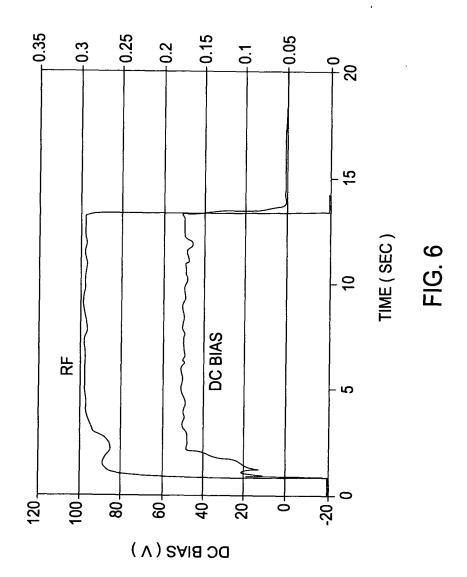
INVENTOR: LIHUA LI, ET AL.

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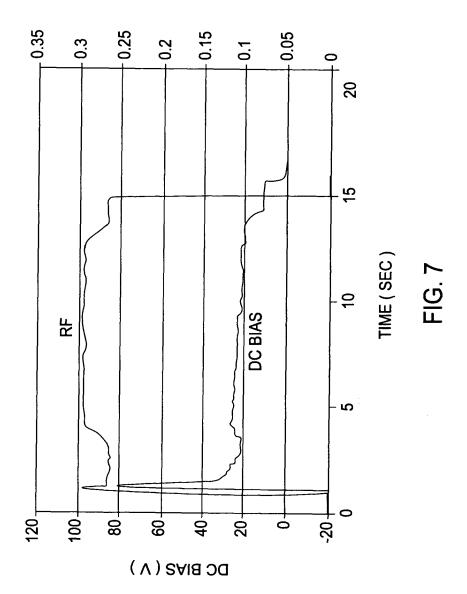
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